

In the Specification:

Please amend paragraph [0001] in the section "Cross-Reference to Related Application" as follows:

Q1 [0001] This application relates to material disclosed in U.S. Application No. 09/945,316 (attorney docket number 10829.8547US) titled "Method and Apparatus for Controlling Radiation Beam Intensity Directed to Microlithographic Substrates," filed on August 30, 2001 and incorporated herein in its entirety by reference.

REMARKS

Applicants respectfully request consideration of the application in view of this preliminary amendment. If the Examiner has any questions or matters that can be expediently handled by telephone, he or she is encouraged to contact Mr. John Wechkin, attorney for the Applicants.

Respectfully submitted,

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**APPENDIX- SPECIFICATION
MARKED TO SHOW CHANGES**

[0001]

This application relates to material disclosed in U.S. Application No. 09/945,316 (attorney docket number 10829.8547US) titled "Method and Apparatus for Controlling Radiation Beam Intensity Directed to Microlithographic Substrates," filed on August 30, 2001 and incorporated herein in its entirety by reference.

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